APPENDIX A

CLEAN COPY OF CLAIMS AS AMENDED HEREIN

1. A process for the preparation of a compound of Formula I:

$$R^1$$
 N
 $X \cdot Y \cdot Z$
 R^2

Formula I

wherein:

R¹ and R² are independently optionally substituted alkyl;

X is pyrazol-4-yl;

Y is a covalent bond or lower alkylene; and

Z is optionally substituted monocyclic aryl or optionally substituted monocyclic

heteroaryl;

comprising;

cyclizing a compound of the formula (3):

wherein R1, R2, X, Y, and Z are as defined above.

- 2. The process of claim 1, wherein the compound of formula (3) is cyclized in an inert solvent in the presence of a base.
- 3. The process of claim 2, wherein the inert solvent is methanol and the base is aqueous sodium hydroxide solution.
- 4. The process of claim 3, wherein R¹ and R² are independently lower alkyl, Y is methylene, and Z is optionally substituted phenyl.
- 5. The process of claim 4, wherein R^1 is n-propyl, R^2 is ethyl, and Z is 3-trifluoromethylphenyl.
 - 6. The process of claim 1, wherein the compound of formula (3):

is prepared by a method comprising contacting a compound of the formula (2);

$$R^1$$
 N
 NH_2
 NH_2
 R^2
 R^2

with a compound of the formula Z-Y-X-CO₂H in the presence of a carbodiimide or with a compound of the formula Z-Y-X-C(O)Hal, where Hal is chloro or bromo.

- 7. The process of claim 6, wherein the compound of formula (3) is reacted with a compound of the formula Z-Y-X-CO₂H in methanol.
- 8. The process of claim 7, wherein the carbodismide is 1-(3-dimethylaminopropyl)-3-ethylcarbodismide.
- 9. The process of claim 6, wherein the compound of formula (3) is reacted with a compound of the formula Z-Y-X-C(O)Cl.
- 10. The process of claim 9, wherein the reaction is carried out in an inert solvent in the presence of a tertiary base.
- 11. The process of claim 10, wherein the inert solvent is acetonitrile and the tertiary base is triethylamine.
- 12. The process of claim 6, wherein R¹ and R² are independently lower alkyl, X is pyrazol-4-yl, Y is methylene, and Z is optionally substituted phenyl.
- 13. The process of claim 12, wherein R¹ is n-propyl, R² is ethyl, and Z is 3-trifluoromethylphenyl, namely 3-ethyl-1-propyl-8-{1-[(3-trifluoromethylphenyl)methyl]pyrazol-4-yl}-1,3,7-trihydropurine-2,6-dione.
 - 14. The process of claim1, wherein the compound of the formula:

is prepared by a method comprising contacting a compound of the formula;

Response to March 31, 2006 Final Office Action Serial No. 10/719,102 CVT No. 01-0163-CIP2

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(16)

with a compound of the formula R¹L, in which L is a leaving group.

- 15. The process of claim 14, wherein R¹ is lower alkyl optionally substituted by cycloalkyl, and L is iodo.
- 16. The process of claim 15, wherein the reaction is carried out in the presence of a base in an inert solvent.
- 17. The process of claim 16, wherein the base is potassium carbonate and the inert solvent is N,N-dimethylformamide.
- 18. The process of claim 17, wherein R¹ and R² are independently lower alkyl, X is pyrazol-4-yl, Y is methylene, and Z is optionally substituted phenyl.
- 19. The process of claim 18, wherein R¹ is n-propyl, R² is ethyl, and Z is 3-trifluoromethylphenyl.
 - 20. The process of claim1, wherein the compound of the formula:

Page 19

(3)

is prepared by a method comprising contacting a compound of the formula;

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with a compound of the formula R²L, in which L is a leaving group.

- 21. The process of claim 20, wherein R² is lower alkyl optionally substituted by cycloalkyl, and L is iodo.
- 22. The process of claim 21, wherein the reaction is carried out in the presence of a base in an inert solvent.
- 23. The process of claim 22, wherein the base is potassium carbonate and the inert solvent is N,N-dimethylformamide.
- 24. The process of claim 23, wherein R¹ and R² are independently lower alkyl, X is pyrazol-4-yl, Y is methylene, and Z is optionally substituted phenyl.
- 25. The process of claim 24, wherein R¹ is n-propyl, R² is ethyl, and Z is 3-trifluoromethylphenyl.

26. The process of claim 14, wherein the compound of the formula:

(16)

is prepared by a method comprising contacting a compound of the formula:

with a compound of the formula Z-Y-X-CO₂H in the presence of a carbodiimide or with a compound of the formula Z-Y-X-C(O)Hal, where Hal is chloro or bromo.

- 27. The process of claim 26, wherein the compound of formula (15) is reacted with a compound of the formula Z-Y-X-CO₂H in methanol.
- 28. The process of claim 27, wherein the carbodiimide is 1-(3-dimethylaminopropyl)-3-ethylcarbodiimide.
- 29. The process of claim 26, wherein the compound of formula (15) is reacted with a compound of the formula Z-Y-X-C(O)Cl.
- 30. The process of claim 29, wherein the reaction is carried out in an inert solvent in the presence of a tertiary base.

- 31. The process of claim 30, wherein the inert solvent is acetonitrile and the tertiary base is triethylamine.
- 32. The process of claim 31, wherein R^1 and R^2 are independently lower alkyl, X is pyrazol-4-yl, Y is methylene, and Z is optionally substituted phenyl.
- 33. The process of claim 32, wherein R^1 is n-propyl, R^2 is ethyl, and Z is 3-trifluoromethylphenyl.
 - 34. The process of claim 19, wherein the compound of the formula:

(13)

is prepared by a method comprising contacting a compound of the formula:

with a compound of the formula Z-Y-X-CO₂H in the presence of a carbodismide or a compound of the formula Z-Y-X-C(O)Hal, where Hal is chloro or bromo.

35. The process of claim 34, wherein the compound of formula (12) is reacted with a compound of the formula Z-Y-X-CO₂H in methanol.

- 36. The process of claim 35, wherein the carbodiimide is 1-(3-dimethylaminopropyl)-3-ethylcarbodiimide.
- 37. The process of claim 34, wherein the compound of formula (12) is reacted with a compound of the formula Z-Y-X-C(O)Cl.
- 38. The process of claim 37, wherein the reaction is carried out in an inert solvent in the presence of a tertiary base.
- 39. The process of claim 38, wherein the inert solvent is acetonitrile and the tertiary base is triethylamine.
- 40. The process of claim 39, wherein R¹ and R² are independently lower alkyl, X is pyrazol-4-yl, Y is methylene, and Z is optionally substituted phenyl.
- 41. The process of claim 40, wherein R^1 is n-propyl, R^2 is ethyl, and Z is 3-trifluoromethylphenyl.
 - 42. The process of claim 34, wherein the compound of the formula:

is prepared by a method comprising the steps of:

a) contacting a compound of the formula:

7025

Response to March 31, 2006 Final Office Action Serial No. 10/719,102 CVT No. 01-0163-CIP2

with hexamethyldisilazane in the presence of an acid catalyst;

- b) contacting the product thus formed with R¹L, where L is a leaving group, followed by;
 - c) contacting the product thus formed:

with a mixture of sodium nitrite in acetic acid/water; and

d) contacting the product thus formed:

with a mixture of aqueous ammonia and sodium dithionite.

43. The process of claim 42, wherein in step a) R¹ is lower alkyl, L is iodo, and the acid catalyst is ammonium sulfate.

Response to March 31, 2006 Final Office Action Serial No. 10/719,102 CVT No. 01-0163-CIP2

44. The process of claim 26, wherein the compound of the formula:

is prepared by a method comprising the steps of:

a) contacting a compound of the formula:

with ethyl cyanoacetate in the presence of a base in a protic solvent;

b) contacting the product thus formed:

with a mixture of sodium nitrite in acetic acid/water, and

c) contacting the product thus formed:

with a mixture of aqueous ammonia and sodium dithionite.

45. The process of claim 44, wherein the base is sodium ethoxide and the protic solvent is ethanol.

46. The process of claim 6, wherein the compound of formula:

$$NH_2$$
 NH_2
 NH_2
 NH_2
 NH_2

is prepared by a method comprising the steps of:

a) contacting a compound of the formula:

with ethyl cyanoacetate in the presence of a base in a protic solvent;

b) contacting the product thus formed:

with the dimethylacetal of N,N-dimethylformamide;

c) contacting the product thus formed:

with a compound of formula R¹L, in which L is a leaving group;

d) contacting the product thus formed:

with aqueous ammonia;

e) contacting the product thus formed:

with a mixture of sodium nitrite in acetic acid/water; and

f) contacting the product thus formed:

with a mixture of aqueous ammonia and sodium dithionite.

47. The process of claim 46, wherein the base is sodium ethoxide and the protic solvent is ethanol.

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